

Supporting Information

Flux Synthesis of Layered Oxyhalide Bi₄NbO₈Cl Photocatalyst for Efficient Z-scheme Water Splitting Under Visible Light

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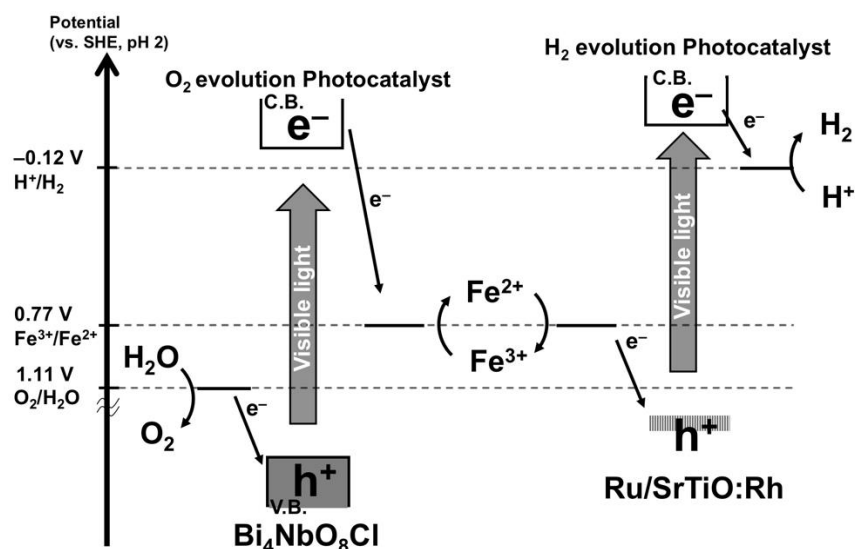


Figure S1. The schematic energy diagram of the Z-scheme water splitting system composed of $\text{Bi}_4\text{NbO}_8\text{Cl}$, $\text{Ru}/\text{SrTiO}_3\text{:Rh}$ and $\text{Fe}^{3+}/\text{Fe}^{2+}$ redox.

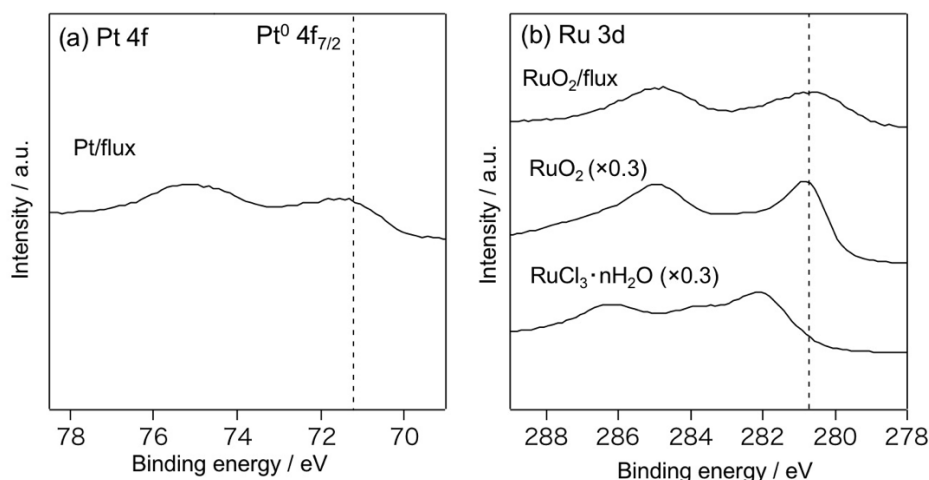


Figure S2. XP spectra of (a) Pt 4f and (b) Ru 3d region of Pt or Ru species loaded $\text{Bi}_4\text{NbO}_8\text{Cl}$ samples prepared via the flux method (CsCl/NaCl flux at 650°C), along with those of commercial RuO_2 (Wako Pure Chemical Industries, Ltd.) and $\text{RuCl}_3 \cdot n\text{H}_2\text{O}$ (Wako Pure Chemical Industries, Ltd) as references for comparison. Each cocatalyst was loaded via impregnation followed by heating under H_2 flow (20 mL min^{-1}) at 150°C for Pt or Ar flow (20 mL min^{-1}) at 450°C for RuO_2 . The binding energy of Pt^0 was referred to a reference hand book.¹

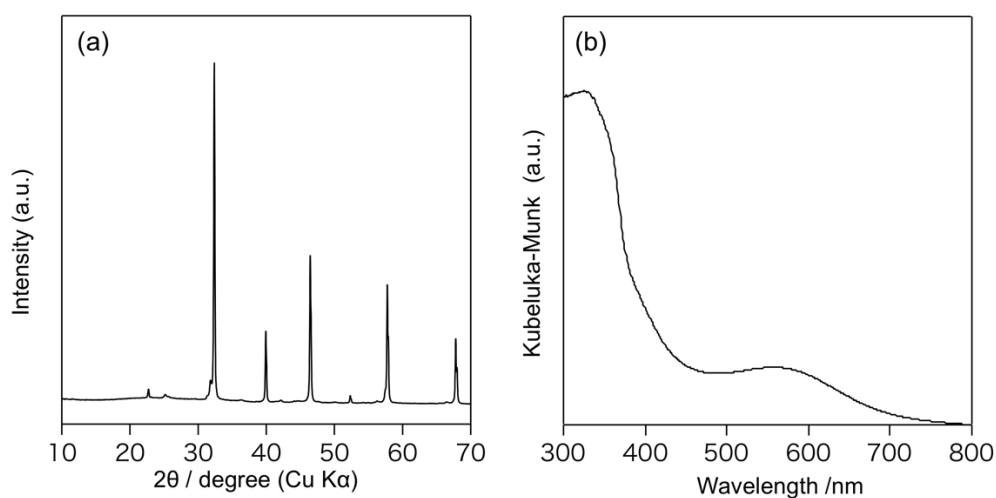


Figure S3. (a) XRD pattern and (b) DRS of as-prepared $\text{SrTiO}_3\text{:Rh}$.

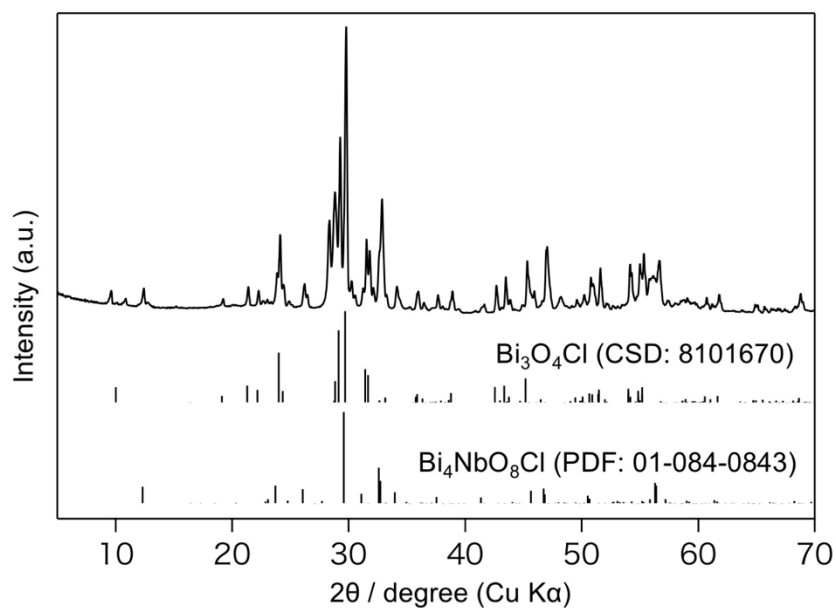


Figure S4. XRD patterns of $\text{Bi}_4\text{NbO}_8\text{Cl}$ prepared by calcination of the mixture of the materials in air at 650 °C without any flux.

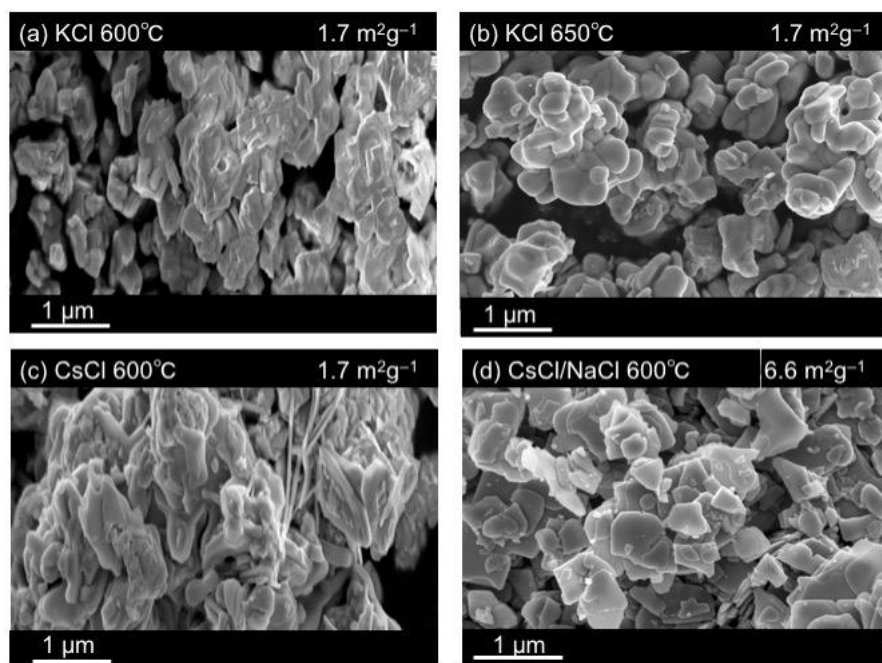


Figure S5. SEM images of $\text{Bi}_4\text{NbO}_8\text{Cl}$ prepared via the flux method (a,b) with KCl at 600 and 650 °C; (c) with CsCl at 600 °C; (d) with CsCl/NaCl at 600 °C.

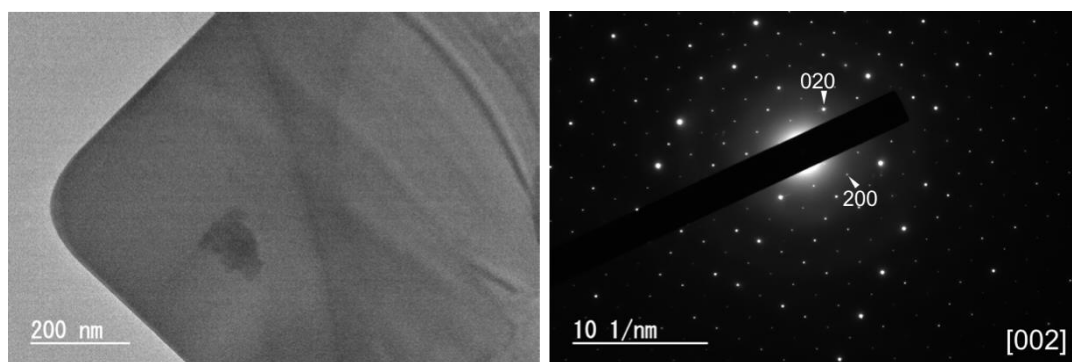


Figure S6. TEM image and electron diffraction patterns of $\text{Bi}_4\text{NbO}_8\text{Cl}$ prepared via the flux method (CsCl/NaCl flux at 650 °C).

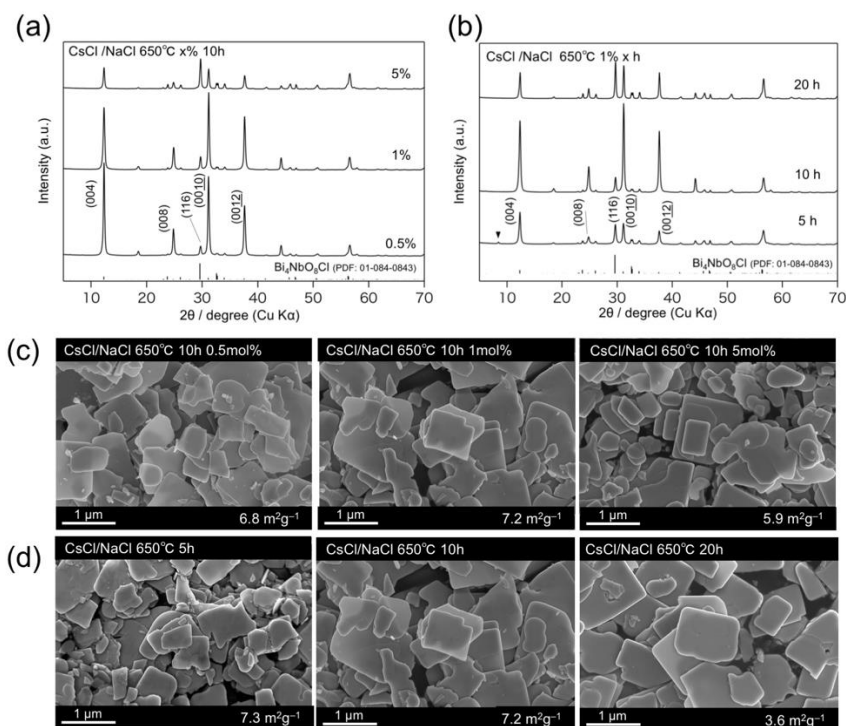


Figure S7. (a,b) XRD patterns and (c,d) SEM images of $\text{Bi}_4\text{NbO}_8\text{Cl}$ prepared with CsCl/NaCl flux at various solute concentrations and calcination times.

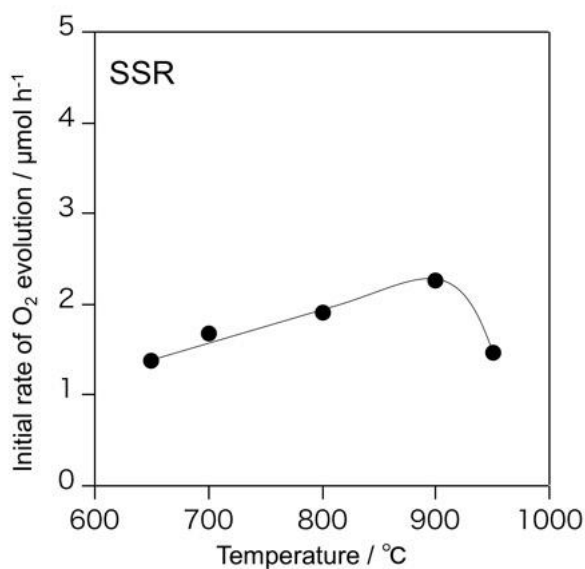


Figure S8. Initial rates of O_2 evolution over $\text{Bi}_4\text{NbO}_8\text{Cl}$ samples prepared at various temperature (650 ~ 950 $^{\circ}\text{C}$) via the solid-state reaction method in an aqueous FeCl_3 solution (8 mM, 100 mL) under visible light irradiation ($\lambda > 400$ nm).

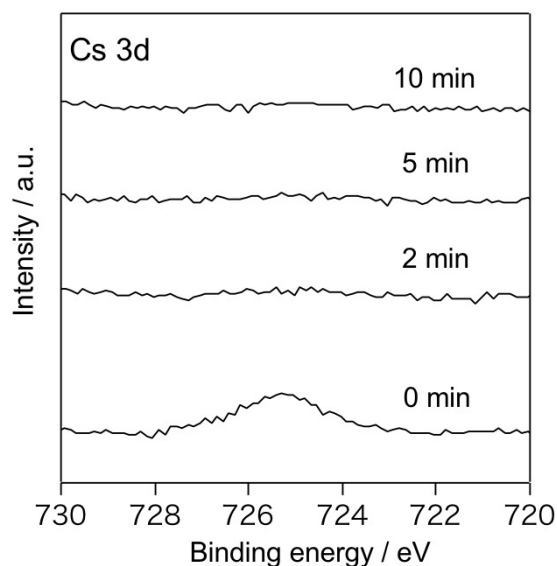


Figure S9. XP spectra of Cs 3d region of the flux sample before and after Ar sputtering (2, 5, 10 min). The binding energies were referenced to the Au 4f_{7/2} level of deposited Au metal.

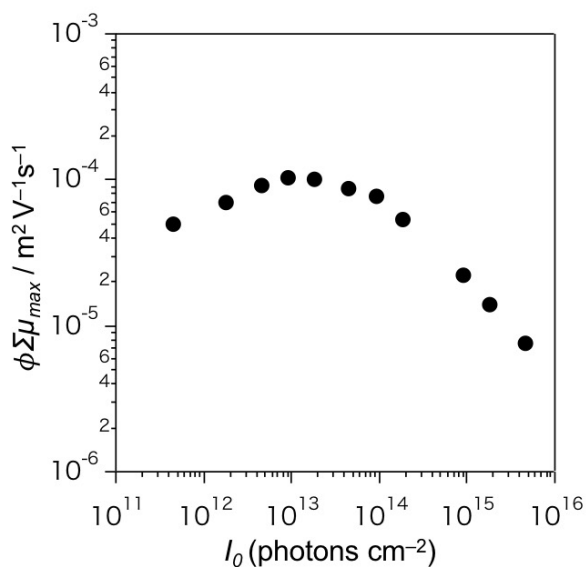


Figure S10. Dependence of $\phi \Sigma \mu_{\max}$ on the incident laser intensity (I_0) of the flux sample. The initial increase of $\phi \Sigma \mu_{\max}$ with increasing I_0 is due to a trap filling effect (an increase and saturation of $\Sigma \mu$), while the gradual decrease at high I_0 is rationalized by a high order deactivation process such as exciton–exciton annihilation, exciton–carrier annihilation, and charge recombination, which occur within the time resolution.^{2,3}

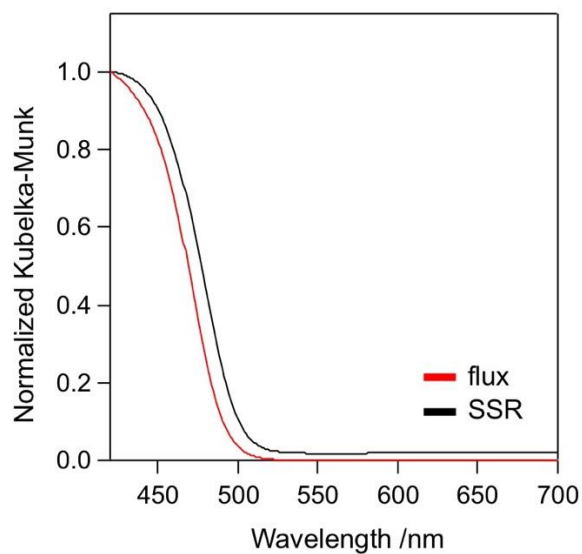


Figure S11. DRS of $\text{Bi}_4\text{NbO}_8\text{Cl}$ samples prepared via the flux method (CsCl/NaCl flux at 650 °C) and the solid-state reaction method.

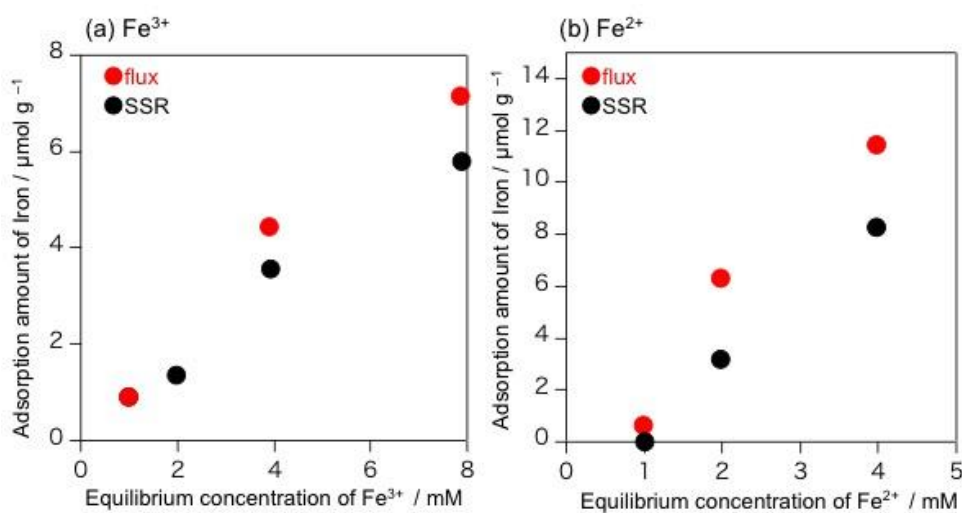


Figure S12. Adsorption properties of (a) Fe^{3+} and (b) Fe^{2+} ions on the $\text{Bi}_4\text{NbO}_8\text{Cl}$ samples prepared via the flux method (CsCl/NaCl flux at 650 °C) and the solid-state reaction method.

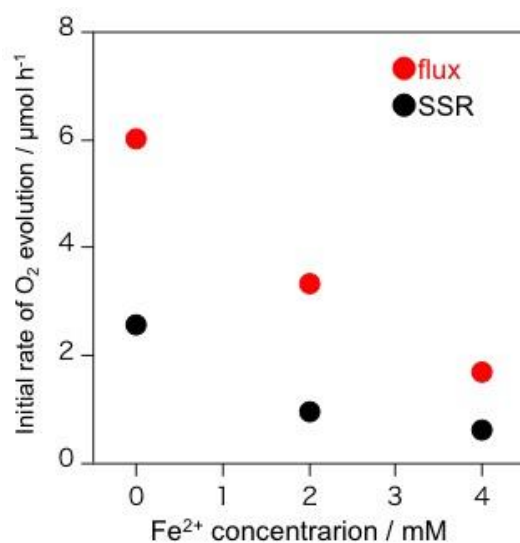


Figure S13. Initial rates of O₂ evolution over Bi₄NbO₈Cl samples prepared via the flux method (CsCl/NaCl flux at 650 °C) and the solid-state reaction method in a solution containing different concentrations of Fe²⁺ (0 ~ 4 mM) and a fixed concentration of Fe³⁺ (8 mM, 100 mL) under visible light irradiation ($\lambda > 400$ nm).

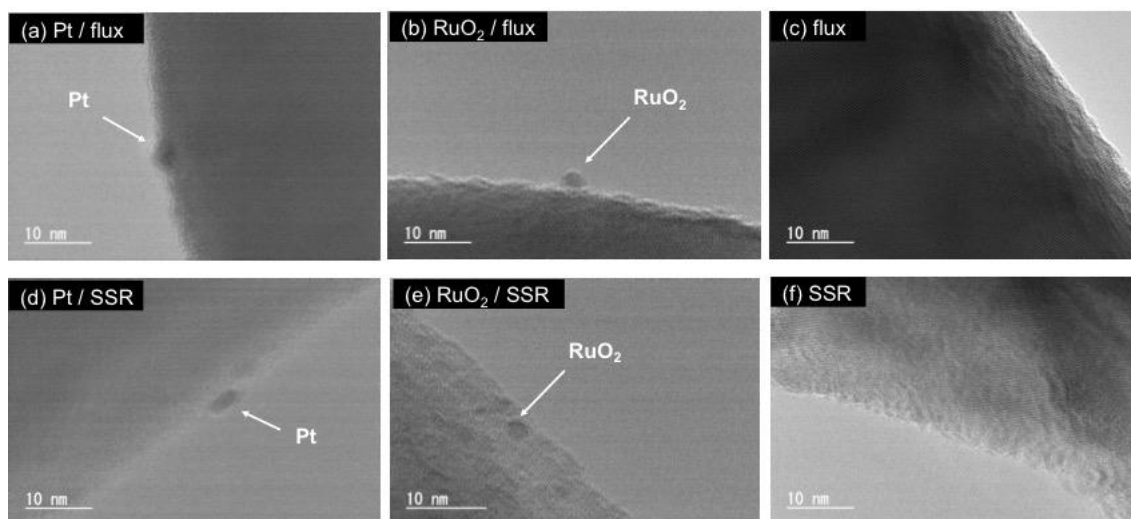


Figure S14. TEM images of (a,d) Pt- or (b,e) RuO₂-loaded Bi₄NbO₈Cl, along with (c,f) unmodified ones. The Bi₄NbO₈Cl samples prepared via (a-c) the flux method (CsCl/NaCl flux at 650 °C) and (d-f) the solid-state reaction method.

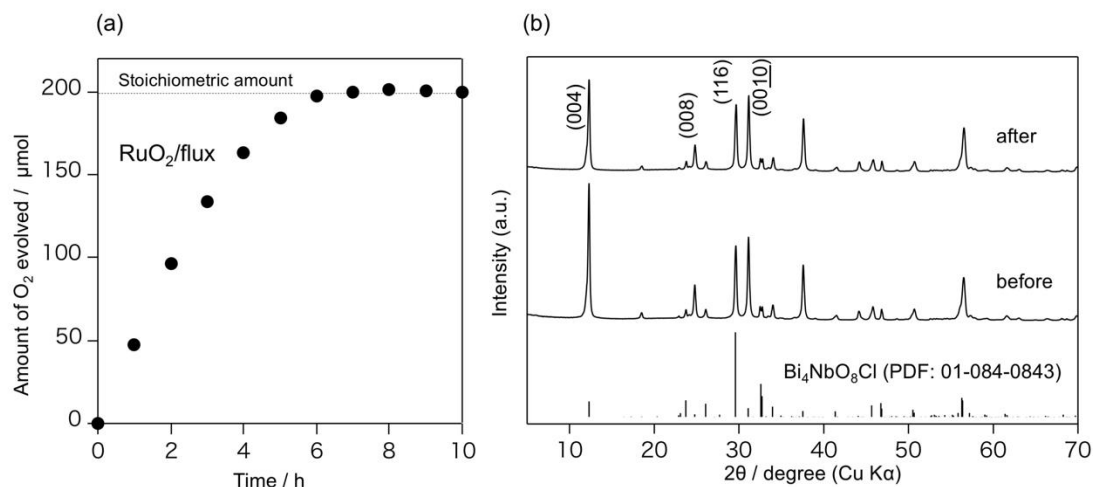


Figure S15. (a) Time course of O₂ evolution over a RuO₂-loaded Bi₄NbO₈Cl sample prepared via the flux method (CsCl/NaCl flux at 650 °C) in an aqueous FeCl₃ solution (8 mM, 100 mL) under visible light irradiation ($\lambda > 400$ nm). (b) XRD patterns of the RuO₂-loaded Bi₄NbO₈Cl before and after the photocatalytic reaction.

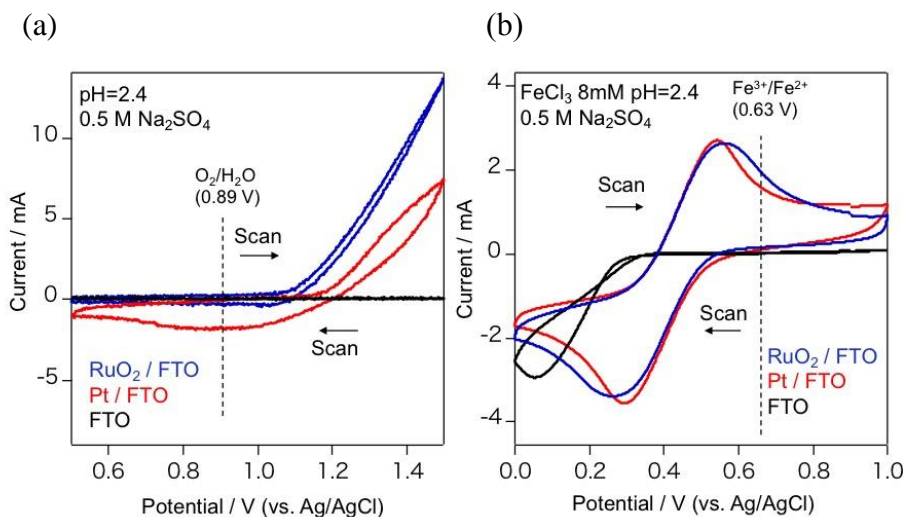


Figure S16. CV profiles of FTO substrates loaded with Pt or RuO₂ in 0.5 M aqueous Na₂SO₄ solution (a) in the absence and (b) presence of Fe³⁺ (8 mM, pH 2.4).

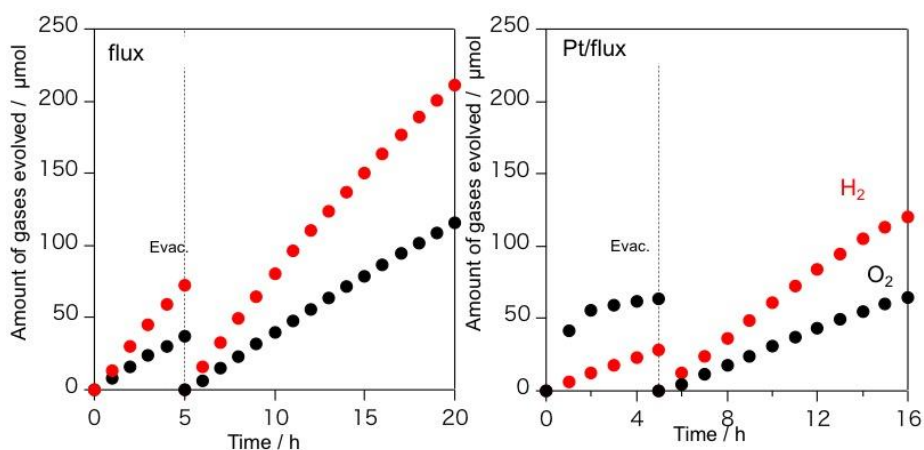


Figure S17. Time courses of H₂ and O₂ evolution over a mixture of bare or Pt-loaded Bi₄NbO₈Cl samples prepared via the flux method (CsCl/NaCl flux at 650 °C) (50 mg) and Ru/SrTiO₃:Rh (50 mg) in FeCl₃ aqueous solution (2 mM, 100 mL) at pH 2.4 under visible light irradiation ($\lambda > 400$ nm).

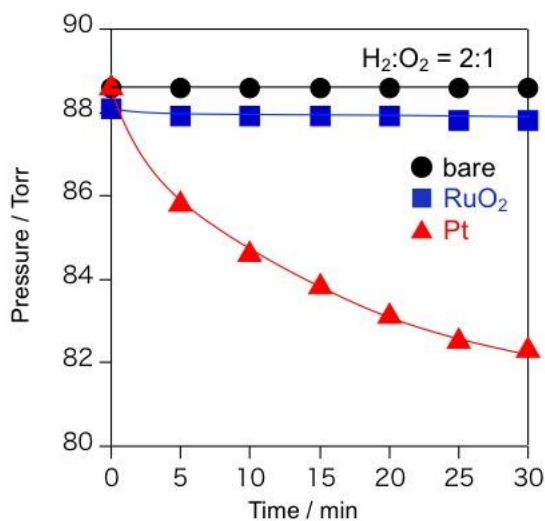


Figure S18. Water formation from H₂ and O₂ in the gas-phase reaction over Pt/flux, RuO₂/flux and flux. A mixture of H₂ and air gases (H₂ : O₂ = 2 : 1) was introduced into a gas-circulating system with a Pyrex glass cell containing 20 mg of photocatalyst powder without water.

References

- (1) Jhon, F. M.; William, F. S.; Kenneth, D. B. *Handbook of X-Rays Photoelectron Spectroscopy*; Jill, C., Ed.; Perkin-Elmer Corporation: Minnesota, 1992.
- (2) Kroeze, J. E.; Savenije, T. J.; Warman, J. M. Electrodeless Determination of the Trap Density, Decay Kinetics, and Charge Separation Efficiency of Dye-Sensitized Nanocrystalline TiO₂. *J. Am. Chem. Soc.* **2004**, *126*, 7608–7618.
- (3) Saeki, A.; Yasutani, Y.; Oga, H.; Seki, S. Frequency-Modulated Gigahertz Complex Conductivity of TiO₂ Nanoparticles: Interplay of Free and Shallowly Trapped Electrons. *J. Phys. Chem. C* **2014**, *118*, 22561–22572.